



## INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

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<b>(21) International Application Number:</b> PCT/US97/11917 <b>(22) International Filing Date:</b> 17 July 1997 (17.07.97)  <b>(30) Priority Data:</b> 683,789                      18 July 1996 (18.07.96)                      US  <b>(71) Applicant:</b> CANDESCENT TECHNOLOGIES CORPORATION [US/US]; 6320 San Ignacio Avenue, San Jose, CA 95119 (US).  <b>(72) Inventors:</b> SPINDT, Christopher, J.; 115 Hillside Avenue, Menlo Park, CA 94025 (US). MORRIS, David, L.; 3644 El Grande Court, San Jose, CA 95132 (US). SCHMID, Anthony, P.; 461 Canyon Drive, Solana Beach, CA 92075 (US). SUN, Yu, Nan; 9964 Alpine Terrace, Sunnyvale, CA 94086 (US).  <b>(74) Agents:</b> HOFFMAN, Eric, E. et al.; Skjerven, Morrill, MacPherson, Franklin & Friel, Suite 700, 25 Metro Drive, San Jose, CA 95110 (US).		<b>(81) Designated States:</b> JP, KR, European patent (AT, BE, CH, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE).  <b>Published</b> <i>With international search report.</i> <i>Before the expiration of the time limit for amending the claims and to be republished in the event of the receipt of amendments.</i>
<b>(54) Title:</b> SPACER STRUCTURES FOR A FLAT PANEL DISPLAY AND METHODS FOR OPERATING SAME		
<b>(57) Abstract</b> <p>Methods and structures are provided which reduce charge build up on spacer walls in a flat panel display. In one embodiment, the order of activating the electron emitting elements is modified such that the electron emitting elements adjacent to the spacers are activated before the electron emitting elements which charge the spacers (501, 502, 503) to an undesirable level. In another embodiment, face electrodes (501a, 502a, 503a) which are located on the surface of the spacer are connected to a common bus (504), thereby distributing the charge built up on any particular spacer. The common bus (504) can further be connected to a capacitor (1010) which is located either inside or outside the active region of the flat panel display, thereby increasing the charging time constant of the spacers. The capacitor can be connected to ground or to a high voltage supply (1011). In another embodiment, the charging time constant of the spacers is increased by fabricating the spacers from a material having a high dielectric constant, such as dispersion of aluminum oxide, chromium oxide and titanium oxide, wherein the titanium oxide makes up approximately four percent of the spacer material.</p>		

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SPACER STRUCTURES FOR A FLAT PANEL DISPLAY AND METHODS  
FOR OPERATING SAME

5    FIELD OF THE INVENTION

          The present invention relates to spacers which are located between a faceplate structure and a backplate structure in a flat panel display. The present invention also relates to methods for operating a flat panel display in conjunction with these spacers.

BACKGROUND OF THE INVENTION

          Flat cathode ray tube (CRT) displays include displays which exhibit an large aspect ratio (e.g., 10:1 or greater) with respect to conventional deflected-beam CRT displays, and which display an image in response to electrons striking a light emissive material. The aspect ratio is defined as the diagonal length of the display surface to the display thickness. The electrons which strike the light emissive material can be generated by various devices, such as by field emitter cathodes or thermionic cathodes. As used herein, flat CRT displays are referred to as flat panel displays.

          Conventional flat panel displays typically include a faceplate structure and a backplate structure which are joined by connecting walls around the periphery of the faceplate and backplate structures. The resulting enclosure is usually held at a vacuum pressure. To prevent collapse of the flat panel display under the vacuum pressure, a plurality of electrically resistive spacers are typically located between the faceplate and backplate structures at a centrally located active region of the flat panel display.

          The faceplate structure includes an insulating faceplate (typically glass) and a light emitting structure formed on an interior surface of the

insulating faceplate. The light emitting structure includes light emissive materials, or phosphors, which define the active region of the display. The backplate structure includes an insulating backplate and an  
5 electron emitting structure located on an interior surface of the backplate. The electron emitting structure includes a plurality of electron-emitting elements (e.g., field emitters) which are selectively excited to release electrons. The light emitting  
10 structure is held at a relatively high positive voltage (e.g., 5 kV) with respect to the electron emitting structure. As a result, the electrons released by the electron-emitting elements are accelerated toward the phosphor of the light emitting structure, causing the  
15 phosphor to emit light which is seen by a viewer at the exterior surface of the faceplate (the "viewing surface").

Fig. 1 is a schematic representation of the viewing surface of a flat panel display 100. The  
20 faceplate structure 20 of flat panel display 100 includes a light emitting structure which is arranged in a plurality of rows of light emitting elements (i.e., pixel rows), such as pixel rows 1-10. Flat panel display 100 typically includes hundreds of pixel  
25 rows, with each row typically including hundreds of pixels. Spacers 101-104 extend horizontally across display 100 in parallel with pixel rows 1-10. Pixel rows 1-10 and spacers 101-104 are greatly enlarged in Fig. 1 for purposes of illustration.

30 The electron emitting structure of flat panel display 100 is arranged in rows of electron emitting elements which correspond with the pixel rows of faceplate structure 20. All of the electron emitting elements in a given row are simultaneously activated  
35 (i.e., fired). The rows of electron emitting elements are sequentially activated. Thus, the row of electron

emitting elements corresponding to pixel row 1 is activated first, followed by the sequential activation of the rows of electron emitting elements corresponding to pixel rows 2-10. The firing order continues in the direction illustrated by arrow 110.

Fig. 2 is a cross sectional view of flat panel display 100 along section line 2-2 of Fig. 1. Fig. 2 illustrates faceplate structure 20, which includes faceplate 21 and light emitting structure 22, backplate structure 30, which includes backplate 31 and electron emitting structure 32, and spacer 101. Light emitting structure 22 includes pixel rows 1-10, and electron emitting structure 32 includes corresponding rows of electron emitting elements 1a-10a.

As previously described, the rows of electron emitting elements 1a-10a are sequentially fired at corresponding pixel rows 1-10. When the electrons emitted from the electron emitting elements 1a-10a strike the light emitting material of pixel rows 1-10, electron scattering occurs. As illustrated for pixel rows 6-9, the scattered electrons can strike spacer 101. The energy of the scattered electrons which strike spacer 101 can be sufficient to free electrons from spacer 101, thereby positively charging the surface of spacer 101. Spacer 101 is rapidly charged as the rows of electron emitting elements approaching spacer 101 are sequentially activated.

When the row (or rows) of electron emitting elements which are located immediately adjacent to spacer 101 (e.g., electron emitting element 10a) are activated, the positive charge which has built up on spacer 101 can be sufficient to deflect the emitted electrons toward spacer 101. As a result, the pixel rows immediately adjacent to spacer 101 (e.g., pixel row 10) may only receive a fraction of the electrons emitted from their corresponding rows of electron

emitting elements, thereby causing these pixel rows to appear dark. Even slight deflection of the emitted electrons can result in perceivable pixel distortion adjacent to spacer 101. That is, electrons emitted from electron emitting element 10a can be deflected and strike pixel row 10 at a position which is off-center within pixel row 10, thereby causing distortion in pixel row 10. For these reasons, the viewer may perceive distorted (e.g., dark or light) pixel lines adjacent to spacer 101.

Prior art spacers have included electrically resistive coatings which help to bleed off the charge which is built up on the spacer surfaces. However, such resistive coatings, by themselves, can be insufficient to reduce the charging of the spacer surfaces to an acceptable level.

It would therefore be desirable to have methods and/or structures which reduce the charging of the spacer surfaces to an acceptable level during operation of flat panel display 100.

#### SUMMARY

Accordingly, one embodiment of the invention includes the steps of logically partitioning the flat panel display into three display regions: spacer-adjacent regions, which are located immediately adjacent to the spacers, (2) spacer-charging regions, which are located adjacent to the spacer adjacent regions, and (3) spacer-neutral regions, which are located adjacent to the spacer-charging regions. The spacer-charging regions include those regions of the flat panel display which, when activated, charge an adjacent spacer to an undesirably high level. The spacer-neutral regions are those regions of the flat panel display which, when activated, do not significantly charge the spacers. To prevent the

spacers from being charged when the spacer-adjacent regions are activated, the spacer-adjacent regions are activated before the spacer-charging regions. A typical operating sequence includes the steps of

5 activating the spacer-neutral regions, activating the spacer-adjacent regions, and then activating the spacer-charging regions. Because the spacers are not excessively charged when the spacer-adjacent regions are activated, the spacer adjacent regions operate

10 properly (i.e., without significant electron deflection), and no dark lines are perceived adjacent to the spacers.

In another embodiment, spacers are made of a material having a high dielectric constant, thereby

15 increasing the charging time constant of the spacers and preventing rapid charge build up on the spacers. In a particular embodiment, the spacers are made of titanium oxide and chromium oxide dispersed in aluminum oxide. The concentration of titanium oxide is

20 controlled to be approximately four percent. By controlling the percentage of titanium oxide to be approximately four percent, the dielectric constant of the spacer material is advantageously maximized. The concentration of chromium oxide and aluminum oxide can

25 be, for example, 64 percent and 32 percent, respectively.

In another embodiment, a face electrode is located on an outer surface of each spacer and a common bus structure connects the face electrodes. The common bus

30 structure advantageously distributes the charge built up on any particular spacer among all of the spacers. In one variation, the common bus structure is formed by an insulating strip located on the faceplate of the flat panel display, adjacent to the light emitting

35 structure, and a conductive bus layer located on the

insulating strip. The conductive bus layer is connected to each of the face electrodes.

5 In another embodiment, a capacitor is coupled to the common bus structure, thereby increasing the charging time constant of the spacers. The capacitor can be physically located inside or outside of the flat panel display. Moreover, the capacitor can be connected to a high voltage supply or a ground voltage supply.

10 The capacitor can be formed within the flat panel display by including a conductive plate between the faceplate and the insulating strip of the common bus structure. The conductive plate and the conductive bus layer form the plates of the capacitor and the  
15 insulating strip forms the dielectric of the capacitor. The conductive plate can be connected to a high voltage supply through the light emitting structure of the faceplate structure.

20 In yet another embodiment, a flat panel display includes a plurality of parallel pixel rows and a plurality of spacers which extend perpendicular to the pixel rows. Each spacer includes a face electrode which distributes excessive charges along the length of the spacer, thereby preventing charge build-up on the  
25 spacer.

The present invention will be more fully understood in view of the following detailed description taken together with the drawings.

30 BRIEF DESCRIPTION OF THE DRAWINGS

Fig. 1 is a schematic representation of the viewing surface of a conventional flat panel display;

Fig. 2 is a cross sectional view of the flat panel display of Fig. 1 along section line 2-2 of Fig. 1;



Fig. 3 is a schematic representation of a portion of a viewing surface of a flat panel display in accordance with one embodiment of the invention;

Fig. 4 is a cross sectional view of the flat panel display of Fig. 3 along section line 4-4 of Fig. 3;

Fig. 5 is a schematic representation of a flat panel display having a common spacer bus in accordance with another embodiment of the present invention;

Fig. 6 is an isometric view of a spacer which is used in several embodiments of the invention;

Fig. 7 is a schematic representation of the upper surface of a flat panel display having a common spacer bus;

Fig. 8 is a cross sectional view of the flat panel display of Fig. 7 along section line 8-8 of Fig. 7;

Fig. 9 is a cross sectional view of the flat panel display of Fig. 7 along section line 9-9 of Fig. 7;

Fig. 10 is a schematic representation of a flat panel display having an external capacitor coupled to a common spacer bus in accordance with another embodiment of the present invention;

Fig. 11 is a schematic representation of the upper surface of a flat panel display having an external capacitor coupled to a common spacer bus;

Fig. 12 is a cross sectional view of the flat panel display of Fig. 11 along section line 12-12 of Fig. 11;

Fig. 13 is a schematic representation of a flat panel display having an internal capacitor coupled to a common spacer bus in accordance with yet another embodiment of the present invention;

Fig. 14 is a schematic representation of the upper surface of a flat panel display having an internal capacitor coupled to a common spacer bus;

Fig. 15 is a cross sectional view of the flat panel display of Fig. 14 along section line 15-15 of Fig. 14;

5 Fig. 16 is a cross sectional view of the flat panel display of Fig. 14 along section line 16-16 of Fig. 14;

10 Fig. 17 is a schematic representation of the upper surface of a flat panel display having spacers located in parallel with pixel rows in accordance with another embodiment of the invention; and

Fig. 18 is an isometric view of a spacer which can be used in the flat panel display of Fig. 17.

#### DETAILED DESCRIPTION

15 The following definitions are used in the description below. Herein, the term "electrically insulating" (or "dielectric") generally applies to materials having a resistivity greater than  $10^{12}$  ohm-cm. The term "electrically non-insulating" thus refers to  
20 materials having a resistivity below  $10^{12}$  ohm-cm. Electrically non-insulating materials are divided into (a) electrically conductive materials for which the resistivity is less than 1 ohm-cm and (b) electrically resistive materials for which the resistivity is in the  
25 range of 1 ohm-cm to  $10^{12}$  ohm-cm. These categories are determined at low electric fields.

Examples of electrically conductive materials (or electrical conductors) are metals, metal-semiconductor compounds, and metal-semiconductor eutectics.  
30 Electrically conductive materials also include semiconductors doped (n-type or p-type) to a moderate or high level. Electrically resistive materials include intrinsic and lightly doped (n-type or p-type) semiconductors. Further examples of electrically  
35 resistive materials are cermet (ceramic with embedded metal particles) and other such metal-insulator

composites. Electrically resistive materials also include conductive ceramics and filled glasses.

#### First Embodiment

5        Fig. 3 illustrates a portion of the viewing surface of a flat panel display 300 in accordance with one embodiment of the invention. Fig. 4 is a cross sectional view of flat panel display 300 along section line 4-4 of Fig. 3. The illustrated portion of flat  
10        panel display 300 includes faceplate structure 320, backplate structure 330 and spacers 351 and 352. Faceplate structure 320 is a conventional structure which includes an electrically insulating glass faceplate 321 and a light emitting structure 322.  
15        Backplate structure 330 is also a conventional structure, and includes electrically insulating backplate 331 and electron emitting structure 332. Faceplate structure 320 and backplate structure 330 are described in more detail in commonly owned U.S. Patent  
20        No. 5,477,105; U.S. Patent Application No. 08/081,913 "Flat Panel Display with Ceramic Backplate" by Curtin et al., filed June 22, 1993; and PCT Publication No. WO 95/07543, published March 16, 1995, which are hereby incorporated by reference in their entirety.  
25        In one variation, each of spacers 351 and 352 is formed from a solid piece of uniform electrically resistive material such as a ceramic containing a transition metal oxide. Each of spacers 351 and 352 can also be formed from an electrically insulating core  
30        having electrically resistive skins formed on the outside surfaces thereof. Spacers 351 and 352 are described in more detail in commonly owned, co-pending U.S. Patent Application No. 08/414,408 "Spacer Structures for Use in Flat Panel Displays and Methods  
35        for Forming Same" by Schmid, et al., filed March 31, 1995; and U.S. Patent Application No. 08/505,841

"Structure and Operation of High Voltage Supports" by Spindt et al., filed July 20, 1995, both of which are hereby incorporated by reference in their entirety.

5 The illustrated portion of flat panel display 300 is logically partitioned into eleven display regions 301-311. Each of display regions 301-311 includes a corresponding light emitting region 301a-311a of light emitting structure 322, and a corresponding electron emitting region 301b-311b of electron emitting  
10 structure 332. Each of light emitting regions 301a-311a includes one or more rows of light emitting elements (i.e., pixel rows) which extend in parallel with spacers 351 and 352. Similarly, each of electron emitting regions 301b-311b includes one or more rows of  
15 electron emitting elements. Each of light emitting regions 301a-311a has a corresponding electron emitting region 301b-311b.

In the described embodiment, the pixels of flat panel display 300 have a pitch (spacing) of 12.5 mils,  
20 although other pitches are possible and considered to be within the scope of the invention. Spacers 351 and 352 extend parallel to each other with a lateral spacing of 375 mils. Thus, thirty pixel rows exist between spacers 351 and 352. Other spacers (not shown)  
25 of flat panel display 300 are identically spaced. Flat panel display 300 can include, for example, 480 pixel rows. Spacers 351 and 352 have a thickness T of approximately 2.25 mils, and a height H of approximately 50 mils. As a result, the spacing  
30 between faceplate structure 320 and backplate structure 330 is approximately 50 mils. A voltage difference of approximately 5 kV is maintained between electron emitting structure 332 and light emitting structure 322.

35 Display regions 303 and 304 are located immediately adjacent to spacer 351, and display regions

308 and 309 are immediately adjacent to spacer 352. Display regions 303, 304, 308 and 309 are therefore hereinafter referred to as spacer-adjacent regions. Spacer-adjacent regions 303, 304, 308 and 309 are  
5 selected to include the pixel rows which would fail to receive an acceptable number of emitted electrons from their corresponding rows of electron emitting elements as a result of charge build up on spacers 351 and 352, assuming that the rows of electron emitting elements  
10 were sequentially activated in the direction of arrow 340. Spacer-adjacent regions 303, 304, 308 and 309 are also selected to include the pixel rows which would receive electrons which are deflected by an amount which results in pixel distortion as a result of charge  
15 built up on spacers 351 and 352, assuming that the rows of electron emitting elements were sequentially activated in the direction of arrow 340.

In the described embodiment, each of spacer-adjacent regions 303, 304, 308 and 309 includes one or  
20 two pixel rows which are located immediately adjacent to spacers 351-352. If, for example, each of spacer-adjacent regions 303, 304, 308 and 309 includes two pixel rows, then light emitting regions 303a, 304a, 308a and 309a would each include two rows of light  
25 emitting elements, and corresponding electron emitting regions 303b, 304b, 308b and 309b would each include two corresponding rows of electron emitting elements.

When electron emitting regions 303b, 304b, 308b and 309b are activated, electrons scattering from the  
30 corresponding light emitting regions 303a, 304a, 308a and 309a do not significantly charge spacers 351 and 352. This is because the electrons which scatter from light emitting regions 303a, 304a, 308a and 309a tend to hit spacers 351 and 352 relatively close to the top  
35 of spacers 351 and 352 (i.e., near light emitting structure 322). As a result, the charge introduced by

these electrons is easily bled off to light emitting structure 322.

Display regions 302, 305, 307 and 310 are located immediately adjacent to spacer-adjacent regions 303, 304, 308 and 309, respectively. Display regions 302, 305, 307 and 310 are selected to include the pixel rows which, when sequentially fired upon by their corresponding rows of electron emitting elements, provide electron scattering which charges spacers 351 and 352 to an undesirably high level. Regions 302, 305, 307 and 310 are hereinafter referred to as spacer-charging regions. Spacer charging regions 302, 305, 307 and 310 include corresponding light emitting regions 302a, 305a, 307a and 310a, and corresponding electron emitting regions 302b, 305b, 307b and 310b. In the described embodiment, each of spacer-charging regions 302, 305, 307 and 310 includes three to five pixel rows which are located immediately adjacent to the corresponding spacer-adjacent regions 303, 304, 308 and 309. If, for example, each of spacer-adjacent regions 303, 304, 308 and 309 includes five pixel rows, then light emitting regions 302a, 305a, 307a and 310a would each include five rows of light emitting elements, and corresponding electron emitting regions 302b, 305b, 307b and 310b would each include five corresponding rows of electron emitting elements.

In a particular embodiment, the pixel rows included in spacer-charging regions 302, 305, 307 and 310 are those pixel rows which are spaced apart from spacers 351 and 352 by a distance in the range of approximately 0.5 to 1.5 times the distance between light emitting structure 322 and electron emitting structure 332.

Display region 301 is located immediately adjacent to spacer-charging region 302, display region 306 is located between spacer-charging regions 305 and 307,

and display region 311 is located immediately adjacent to spacer-charging region 310. Display regions 301, 306 and 311 are selected to include the pixel rows which, when fired upon by their corresponding rows of electron emitting elements, do not scatter electrons in a manner which significantly charges spacers 351 and 352. That is, when the pixel rows in display regions 301, 306 and 311 are fired upon, the electrons which scatter from corresponding light emitting regions 301a, 306a and 311a either fail to reach spacers 351 and 352, or fail to significantly charge spacers 351 and 352 upon reaching these spacers. Regions 301, 306 and 311 are hereinafter referred to as spacer-neutral regions.

In the described embodiment, each of spacer-neutral regions 301, 306 and 311 is laterally separated from spacers 351 and 352 by approximately 5 to 7 pixel rows. Thus, each of spacer-neutral regions 301, 306 and 311 includes 16 to 22 pixel rows which are located immediately adjacent to the corresponding spacer-charging regions 302, 305, 307 and 310. If, for example, each of spacer-neutral regions 301, 306 and 311 includes 16 pixel rows, then light emitting regions 301a, 306a, and 311a would each include sixteen rows of light emitting elements, and corresponding electron emitting regions 301b, 306b and 311b would each include sixteen corresponding rows of electron emitting elements.

In a particular embodiment, the pixel rows included in spacer-neutral regions 301, 306 and 311 are those pixel rows which are spaced apart from spacers 351 and 352 by a distance which is greater than 1.5 times the distance between light emitting structure 322 and electron emitting structure 332.

In accordance with one embodiment of the invention, electron emitting regions 301b-311b are activated in the order described below. Within each of

electron emitting regions 301b-311b, the rows of electron emitting elements are sequentially activated in the direction indicated by arrow 340 (Fig. 3). The activation order is controlled by a row addressing  
5 system of flat panel display 300.

First, the electron emitting elements of electron emitting region 301b are sequentially activated within spacer-neutral region 301. As previously described, the activation of electron emitting region 301b does  
10 not excessively charge spacer 351. Next, the electron emitting elements of electron emitting regions 303b and 304b are sequentially activated within spacer-adjacent regions 303 and 304. Because spacer 351 is not  
15 excessively charged at the time that electron emitting regions 303b and 304b are activated, the electrons emitted from these regions 303b and 304b pass to corresponding light emitting regions 303a and 304b without significant deflection. In a particular  
20 embodiment, electron emitting region 303b is activated before electron emitting region 304b.

Next, the electron emitting elements of electron emitting regions 302b and 305b are sequentially activated within spacer-charging regions 302 and 305. In a particular embodiment, electron emitting region  
25 302b is activated before electron emitting region 305b. Although the activation of electron emitting regions 302b and 305b causes charge to build up on spacer 351, this charge is dissipated by the time that the electron emitting regions 303b and 304b of spacer-adjacent  
30 regions 303 and 304 are subsequently activated. For example, assuming that flat panel display 300 has a refresh frequency of 70 hz, spacer 351 has approximately 14.3 milliseconds in which to discharge before the time that electron emitting regions 303b and  
35 304b are subsequently activated.



The electron emitting elements of electron emitting region 306b are then sequentially activated within spacer-neutral region 306. As previously described, the activation of electron emitting region 5 306b does not excessively charge spacers 351 or 352. Next, the electron emitting elements of electron emitting regions 308b and 309b are sequentially activated within spacer-adjacent regions 308 and 309. Because spacer 352 is not excessively charged at the 10 time that electron emitting regions 308b and 309b are activated, the electrons emitted from these regions 308b and 309b pass to corresponding light emitting regions 308a and 309b without significant deflection.

Next, the electron emitting elements of electron 15 emitting regions 307b and 310b are sequentially activated within spacer-charging regions 307 and 310. Again, the charge built up on spacer 351 in response to the activation of electron emitting regions 307b and 310b is dissipated by the time that electron emitting 20 regions 308b and 309b are subsequently activated. The electron emitting elements of electron emitting region 311b are then sequentially activated within spacer-neutral region 311.

The activation of other electron emitting regions 25 (not shown) of flat panel display 300 continues in the manner previously described for electron emitting regions 301b-311b. Eventually, the activation order returns to electron emitting region 301b of spacer-neutral region 301 and the previously described order 30 is repeated. Again, by the time that electron emitting regions 303b-304b and 308b-309b of spacer-adjacent regions 303-304 and 308-309 are activated for the second time, the charge on spacers 351 and 352 have had sufficient time to dissipate.

35 Because the electrons emitted from electron emitting regions 303b, 304b, 308b and 309b are routed

to corresponding light emitting regions 303a, 304a, 308a and 309a without substantial deflection, the image displayed at the viewing surface of faceplate 321 advantageously does not exhibit dark lines adjacent to spacers 351 and 352.

Electron emitting regions 301b-311b can be fired in other sequences and still fall within the scope of the invention. However, the electron emitting regions 303b, 304b, 308b and 309b of spacer-adjacent regions 303, 304, 308 and 309 should not be activated immediately after the activation of the electron emitting regions 302b, 305b, 307b and 310b of spacer-charging regions 302, 305, 307 and 310.

#### Second Embodiment

In accordance with another embodiment of the invention, spacers 351 and 352 are fabricated such that these spacers exhibit a relatively high dielectric constant. A high dielectric constant is defined as being greater  $100\epsilon_0$ , where  $\epsilon_0$  is equal to  $8.85 \times 10^{-12}$  farads/meter. A high dielectric constant can further be defined as being in the range of  $400\epsilon_0$  to  $800\epsilon_0$ . As a result of the high dielectric constant of the spacers, the charging time constant associated with spacers 351 and 352 is increased, thereby preventing rapid charging of these spacers. By preventing rapid charge build-up on spacers 351 and 352, the deflection of electrons emitted by electron emitting regions 303b, 304b, 308b and 309b of spacer-adjacent regions 303, 304, 308 and 309 is minimized. In accordance with one variation of this embodiment, the rows of electron emitting elements of flat panel display 300 are activated in the manner described above in connection with the first embodiment. Alternatively, the rows of the electron emitting elements of flat panel display 300 can be activated sequentially.

In accordance with one variation of the present embodiment, high-dielectric constant spacers are fabricated to include titanium oxide ( $\text{TiO}_2$ ), aluminum oxide ( $\text{AlO}_2$ ) and chromium oxide ( $\text{Cr}_2\text{O}_3$ ) in the percentages listed below in Table 1.

TABLE 1

	Titanium Oxide =	4.0 %
	Aluminum Oxide =	32.0 %
10	Chromium Oxide =	64.0 %

By maintaining the percentage of titanium oxide at or about 4 percent, the dielectric constant of the spacer is maintained at a relatively high level. A spacer having the composition listed above in Table 1 is hereinafter referred to as a "4/32/64" spacer. A 4/32/64 spacer exhibits a dielectric constant of approximately  $700\epsilon_0$  to  $750\epsilon_0$  at a frequency of 1200 to 1500 Hz. In comparison, a spacer having a composition of only 1.6 % titanium oxide, 34.4 % aluminum oxide and 64.0 % chromium oxide exhibits a dielectric constant of approximately  $10\epsilon_0$  or  $11\epsilon_0$  at 100 Hz. Thus, by controlling the percentage of titanium oxide to be approximately 4 percent, a significant increase in the dielectric constant of spacers 351 and 352 is realized.

In addition, the 4/32/64 spacer advantageously exhibits other properties which are considered advantageous in a flat panel display environment. More specifically, the 4/32/64 spacer exhibits a relatively high electrical resistance of approximately  $7 \times 10^8$  ohms/square. Thus, by holding the percentage of titanium oxide at approximately 4 percent, the spacer is maintained within an acceptable range of electrical resistivity. In addition, the 4/32/64 spacer exhibits a secondary emission ratio in the range of 1 to 2.2 at voltages between 1 kV and 4 kV.

In one variation of the present embodiment, the 4/32/64 spacer is fabricated from a slurry created by mixing ceramic powders, organic binders and a solvent in a conventional ball mill. Table 2 sets forth a  
5 formula for such a slurry.

Table 2

	Aluminum oxide powder	103.7 grams
	Chromium oxide powder	207.3 grams
10	Titanium oxide powder	12.9 grams
	Butvar B76	34 grams
	Santicizer 150	10 grams
	Kellox Z3 Menahden oil	0.65 gram
	Ethanol	105 grams
15	Toluene	127 grams

In other variations, the ceramic formula also contains modifiers chosen to control grain size or aid sintering. Compounds such as silicon dioxide,  
20 magnesium oxide, and calcium oxide can be used as modifiers.

Using conventional methods, the milled slurry is used to cast a tape having a thickness of 60-120  $\mu\text{m}$ . In one variation, this tape is cut into large wafers  
25 which are 10 cm wide by 15 cm long. The wafers are then loaded onto a flat conventional setter and fired in air and/or a reducing atmosphere until the wafers exhibit the desired resistivity.

In particular, the wafers are typically fired in a cold wall periodic kiln using a hydrogen atmosphere  
30 with a typical dew point of 24°C. If the organic components of the wafer are to be pyrolyzed (i.e.,

removed) in the same kiln, the dew point of the hydrogen atmosphere will be higher (approximately 50°C) to facilitate removal of the organics without damaging the wafers. The dewpoint will be shifted from the higher dew point (50°C) to the lower dewpoint (24°C) after the organic components of the wafer are pyrolyzed. Pyrolysis is typically complete at a temperature of 600°C. Typically, the wafers are fired at a peak temperature of 1500°C for 1-2 hours. The properties of the ceramic composition are controlled by the detailed firing profile. Depending on the starting raw materials, and on the exact combination of strength, resistivity, and secondary electron emission desired in the spacer, the actual peak temperature may be between 1450°C and 1750°C, and the firing profile may maintain this peak temperature from 1 to 5 hours. The wafers are then unloaded, inspected and cut into strips which are used as spacers 351 and 352. In one variation, these strips are approximately 2.25 mils thick, 2 inches long, and 50 mils tall.

In addition to controlling the electrical resistivity of the spacers by varying the percentage of titanium oxide, the electrical resistivity of the spacers can also be controlled by controlling the percentage of chromium oxide. By increasing the percentage of chromium oxide, the electrical conductivity of the spacer can be increased. However, increasing the percentage of chromium oxide also increases the required sintering temperature of the spacer material. The electrical resistivity can also be controlled by controlling the partial pressure of oxygen ( $PO_2$ ) in the furnace during firing or by changing the dewpoint in the furnace by modifying the  $H_2$  to  $O_2$  ratio.

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### Third Embodiment

Fig. 5 is a schematic diagram of a flat panel display 500 in accordance with another embodiment of the present invention. The present embodiment can be used in combination with the previously described second embodiment, or independent of the second embodiment. In flat panel display 500, a plurality of spacers, such as spacers 501-503, are connected between a faceplate structure 510 and a backplate structure 511. Each of spacers 501-503 additionally includes a corresponding face electrode 501a-503a which is connected to a common bus 504. Each of face electrodes 501a-503a is located on an outer surface of its corresponding spacer 501-503 at a location between the faceplate structure 510 and the backplate structure 511. Common bus 504 effectively combines the resistances and capacitances of spacers 501-503. Common bus 504 also distributes charge among all of spacers 501-503. For example, when a spacer-charging region adjacent to spacer 501 is activated, the resulting charge will be distributed among spacers 501, 502 and 503 by common bus 504. This advantageously reduces the charge built up on spacer 501 (compared to the charge which would have been built up on spacer 501 in the absence of common bus 504). Although the charge built up on spacers 502 and 503 is increased at this time (compared to the charges which would have been built up on spacers 502 and 503 in the absence of common bus 504), such an increase is acceptable, since the spacer-adjacent regions corresponding to spacers 502 and 503 are not activated until some future time.

Fig. 6 is an isometric view of a spacer 601 which can be used in the present embodiment. Spacer 601 includes a spacer body 602, face electrodes 603-604, and edge electrodes 606a, 606b and 607. In one variation, spacer body 602 is made of the 4/32/64 spacer material previously described in the second

embodiment. Alternatively, spacer body 602 is made of another conventional spacer material, including, but not limited to, a solid piece of uniform electrically resistive material such as a ceramic containing a transition metal oxide, or an electrically insulating core having electrically resistive skins. Face electrodes 603 and 604, and edge electrodes 606a, 606b and 607 are made of an electrically conductive material such as aluminum or copper. The fabrication of face electrodes 603 and edge electrodes 606a, 606b and 607 are described in more detail in commonly owned co-pending U.S. Patent Application Serial No. 08/414,408.

Face electrodes 603 and 604 and edge electrodes 606a, 606b and 607 control the voltage distribution along spacer 601. Because spacer 601 has a thickness  $T$  of approximately 2.25 mils, which is relatively small compared to its height  $H$  of 50 mils, face electrodes 603 and 604 are only required on one surface of spacer body 602 to control the voltage distribution throughout spacer 601.

A gap 605 exists between edge electrodes 606a and 606b. The dimensions of gap 605 are selected such that edge electrode 606a is electrically isolated from edge electrode 606b. In a particular embodiment, gap 605 has a width  $W$  of approximately 50 mils. As described in more detail below, edge electrode 606a provides an electrical connection to the light emitting structure of a flat panel display, edge electrode 606b provides an electrical connection between face electrode 603 and a common bus, and edge electrode 607 provides an electrical connection to the electron emitting structure of a flat panel display.

Fig. 7 is a schematic representation of the upper surface of a flat panel display 700. Fig. 8 is a cross sectional view of flat panel display 700 along section line 8-8 of Fig. 7. Fig. 9 is a cross sectional view

of flat panel display 700 along section line 9-9 of Fig. 7. Flat panel display 700 includes spacers 701-707, faceplate structure 720, backplate structure 730, common bus structure 723 and sidewall structure 724.

- 5 Faceplate structure 720 includes insulating faceplate 721 and light emitting structure 722. Backplate structure 730 includes insulating backplate 731 and electron emitting structure 732.

- 10 In the described embodiment, each of spacers 701-707 is identical to spacer 601 (Fig. 6). As illustrated in Fig. 7, spacers 701-707 extend horizontally across light emitting structure 722 in parallel with the pixel rows of flat panel display 700. Light emitting structure 722 defines the viewing  
15 surface of flat panel display 700. Common bus structure 723 is laterally separated from this viewing surface. Sidewall structure 724 laterally surrounds the light emitting structure 722 and common bus structure 723.

- 20 As illustrated in Fig. 8, sidewall structure 724 extends between faceplate structure 720 and backplate structure 730. Light emitting structure 722 of faceplate structure 720 includes a light emissive material 722a, a matrix 722b and a conductive layer  
25 722c. Conductive layer 722c extends outside the outer boundary of sidewall structure 724 and is connected to a power supply 740. Common bus structure 723 includes an insulating strip 723a and a conductive bus layer 723b. In one embodiment, insulating strip 723a is  
30 formed at the same time as matrix 722b, thereby assuring that insulating strip 723a and matrix 722b have substantially the same thickness. In a particular variation, insulating strip 723a and matrix 722b are formed from polyimide, and have a thickness T of  
35 approximately 2 mils. Insulating strip 723a further has a width W of approximately 50 to 100 mils.



Conductive layers 722c and 723b can also be formed at the same time. The thicknesses of conductive layers 722c and 723b are negligible with respect to the thicknesses of insulating strip 723a and matrix 722b.

5 Because insulating strip 723a and matrix 722b have approximately the same thickness, conductive layers 722c and 723b are located at the same distance from faceplate 721, thereby facilitating contact between conductive layers 722c and 723b and spacers 701-707.

10 Still referring to Fig. 8, spacer 707 includes body 757, edge electrodes 767a, 767b, and 768, face electrodes 777 and 778, and gap 755. Spacer 707 is connected between faceplate structure 720 and backplate structure 730 such that conductive layer 722c of light  
15 emitting structure 722 contacts edge electrode 767a, conductive bus layer 723b of common bus structure 723 contacts edge electrode 767b, and electron emitting structure 732 of backplate 730 contacts edge electrode 768. Gap 755 electrically isolates edge electrodes  
20 767a and 767b. Face electrode 777 is electrically connected to edge electrode 767b as illustrated. Each of the remaining spacers 701-706 are connected in the same manner as spacer 707. Although not illustrated in Fig. 8, it is understood that the top portion of spacer  
25 707 could be engaged with a spacer support structure on faceplate structure 720. Such a spacer support structure is not illustrated for purposes of clarity. However, such spacer support structures are described in more detail in commonly owned, co-pending U.S.  
30 Patent Application Serial Nos. 08,188,855, filed January 31, 1994, and 08/343,074, filed November 21, 1994, which are hereby incorporated by reference in their entirety.

As illustrated in Fig. 9, each of spacers 701-706  
35 has a corresponding face electrode 771-776 which contacts a corresponding edge electrode 761-766 in the

same manner previously described for spacer 707. Each of edge electrodes 761-766 contacts conductive bus layer 723b in the same manner as spacer 707. As a result, conductive bus layer 723b provides a common bus which connects face electrodes 771-777. In one variation, conductive bus structure 723 has a length L of approximately 8 inches.

If the rows of electron emitting elements of electron emitting structure 732 are fired in the direction indicated by arrow 780, spacer 701 will be the first one of spacers 701-707 to be exposed to conditions which could result in spacer charge build-up. However, the common connection of face electrodes 771-777 through conductive bus layer 723b increases the effective capacitance of spacer 701, thereby preventing rapid charge build-up on spacer 701. The charge build-up rate on spacers 702-707 is similarly reduced by the common connection of face electrodes 771-777 to conductive bus layer 723b.

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#### Fourth Embodiment

Fig. 10 is a schematic diagram of a flat panel display 1000 in accordance with another embodiment of the present invention. Like the third embodiment, the present embodiment can be used in combination with the previously described first and second embodiments, or independent of these previously described embodiments. Because the flat panel display 1000 illustrated in Fig. 10 is similar to the flat panel display 500 illustrated in Fig. 5, similar elements in Figs. 5 and 10 are labeled with similar reference numbers. Fig. 10 additionally includes external capacitor 1010 which is connected between common bus 504 and ground 1011. Capacitor 1010 increases the effective capacitance of spacers 501-503, thereby further increasing the

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charging time constant associated with spacers 501-503 and preventing rapid charging of these spacers.

Fig. 11 is a schematic representation of the upper surface of a flat panel display 1100 in accordance with the present embodiment. Fig. 12 is a cross sectional view of flat panel display 1100 along section line 12-12 of Fig. 11. Because flat panel display 1100 is similar to flat panel display 700 (Figs. 7-9), similar elements in flat panel displays 700 and 1100 are labeled with similar reference numbers. In addition to the previously described elements of flat panel display 700, flat panel display 1100 additionally includes a common bus extension member 1101 which contacts the conductive bus layer 723b of common bus structure 723. In one variation, common bus extension member 1101 and conductive bus layer 723b are fabricated as a continuous element (See, Fig. 12). Bus extension member 1101 extends along faceplate 721 to a location outside of the outer perimeter of sidewall structure 724. External capacitor 1010 is connected to the bus extension member 1101 at a point which is outside the outer perimeter of sidewall structure 724. In this manner, bused face electrodes 771-777 are connected to an external capacitor 1101. This increases the capacitance of spacers 701-707 and prevents fast charge build-up on these spacers.

#### Fifth Embodiment

Fig. 13 is a schematic diagram of a flat panel display 1300 in accordance with yet another embodiment of the present invention. Like the third and fourth embodiments, the present embodiment can be used in combination with the previously described first and second embodiments, or independent of these previously described embodiments. Because flat panel display 1300 is similar to flat panel display 500 (Fig. 5), similar

elements in Figs. 5 and 13 are labeled with similar reference numbers. Fig. 13 additionally includes a capacitor 1310 which is connected between common bus 504 and voltage supply 1311. Capacitor 1310 increases the effective capacitance of spacers 501-503, thereby further increasing the charging time constant associated with spacers 501-503 and preventing rapid charging of these spacers.

Fig. 14 is a schematic representation of the upper surface of a flat panel display 1400 in accordance with the present embodiment. Fig. 15 is a cross sectional view along section line 15-15 of Fig. 14, and Fig. 16 is a cross sectional view along section line 16-16 of Fig. 14. Because flat panel display 1400 is similar to flat panel display 700 (Figs. 7-9), similar elements are labeled with similar reference numbers.

Flat panel display 1400 includes a capacitor structure 1310 which is fabricated on the interior surface of faceplate 721. As illustrated in Fig. 14, capacitor structure 1310 is located outside of the viewing surface of display 1400 in a location similar to the location of common bus structure 723 (Fig. 7).

As illustrated in Figs. 15 and 16, capacitor structure 1310 includes first conductive plate 1301, dielectric layer 1302 and second conductive plate 1303. In the illustrated embodiment, first conductive plate 1301 is continuous with conductive layer 722c of light emitting structure 722. That is, first conductive plate 1301 and conductive layer 722c are deposited at the same time to form a continuous layer of conductive material. Dielectric layer 1302 can be, for example, a layer of polyimide having a thickness T of approximately 2 mils, a width W of approximately 50 to 100 mils and a length L of approximately 8 inches. Second conductive plate 1303 is deposited on the lower surface of dielectric layer 1302. The combined

thickness of plates 1301, 1303 and dielectric layer 1302 are selected to be equal to the combined thickness of matrix 722b and conductive layer 722c of light emitting structure 722. As a result, both capacitor structure 1310 and light emitting structure 722 make good electrical contact with spacers 701-707.

First and second conductive plates 1301 and 1303 and dielectric layer 1302 form a capacitor. The first conductive plate 1301 of this capacitor is connected to voltage supply 1311 through conductive layer 722c of light emitting structure 722 (Fig. 15). The second conductive plate 1303 of this capacitor is connected to face electrodes 771-777, such that face electrodes 771-777 extend in parallel from second conductive plate 1303. The capacitance of capacitor structure 1310 is determined by the thickness (T), cross sectional area (L x W), and dielectric constant of dielectric layer 1302. These parameters can be varied to create a capacitor structure 1310 having the desired capacitance. In the described embodiment, capacitor structure 1310 has a capacitance in the range of approximately 3 to 6 nanofarads.

In another variation of the present embodiment, the first conductive plate 1301 is not connected to conductive layer 722c of light emitting structure 722. Instead, first conductive plate 1301 is routed outside the outer perimeter of sidewall structure 724 (See, e.g., extension member 1101 of Fig. 11) and connected to a ground voltage supply.

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#### Sixth Embodiment

Fig. 17 is a schematic representation of the upper surface of a flat panel display 1700 in accordance with another embodiment of the present invention. Flat panel display 1700 includes a plurality of spacers 1701-1705 which are disposed perpendicular to (as

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opposed to in parallel with) the pixel rows. Dashed line 1710 represents one of these pixel rows. As the pixel rows of flat panel display 1700 are activated, each of spacers 1701-1705 is charged at a location which is immediately adjacent to the activated pixel row. For example, when pixel row 1710 is activated, spacers 1701-1705 tend to charge at locations 1701a-1705a.

Fig. 18 is an isometric view of spacer 1701. Spacers 1702-1705 are identical to spacer 1701. Spacer 1701 includes spacer body 1711, edge electrodes 1712-1713 and face electrode 1714. The various elements of spacer 1701 are substantially identical to the elements of spacer 601, which were previously described in connection with Fig. 6. Face electrode 1714 is located approximately half way up the height of spacer 1701 and extends along the length of spacer body 1711, substantially in parallel with edge electrodes 1712 and 1713. When a particular location along spacer 1701, such as location 1701a, is subjected to excessive charge, face electrode 1714 allows this charge to be distributed (and dissipated) along the length of spacer 1701 as indicated by arrows 1721 and 1722. Consequently, there is no excessive charge build-up along spacers 1701-1705 at locations adjacent to activated pixel rows.

Although the invention has been described in connection with several embodiments, it is understood that this invention is not limited to the embodiments disclosed, but is capable of various modifications which would be apparent to one of ordinary skill in the art. For example, common bus structure 723 and capacitor structure 1310 can be fabricated on the backplate as well as the faceplate. Thus, the invention is limited only by the following claims.

CLAIMS

What is claimed is:

1. A method for displaying a frame of pixel  
5 information on a flat panel display having a faceplate structure, a backplate structure, and a spacer located between the faceplate and backplate structures, the method comprising the steps of:
  - 10 selecting a pair of spacer-adjacent regions of the flat panel display which are adjacent to the spacer on either side of the spacer;
  - selecting a pair of spacer-charging regions of the flat panel display which are adjacent to the spacer-adjacent regions, wherein the spacer-  
15 charging regions, when activated, charge the spacer;
  - activating the spacer-adjacent regions; and then, for the same frame of pixel information, activating the spacer-charging regions.  
20
2. The method of Claim 1, further comprising the steps of:
  - 25 defining spacer-neutral regions of the flat panel display which are adjacent to the spacer-charging regions, wherein the spacer-neutral regions, when activated, do not charge the spacer; and
  - activating the spacer-neutral regions before the step of activating the spacer-adjacent  
30 regions.
3. The method of Claim 1, further comprising the steps of:
  - 35 defining spacer-neutral regions of the flat panel display which are adjacent to the spacer-charging regions, wherein the spacer-neutral

regions, when activated, do not charge the spacer;  
and

5           activating the spacer-neutral regions after  
the step of activating the spacer-charging  
regions.

4.    A flat panel display comprising:  
        a faceplate structure having an insulating  
        faceplate and a light emitting structure;  
10       a backplate structure having an insulating  
backplate and an electron emitting structure;  
        a plurality of spacers located between the  
faceplate and backplate structures, each spacer  
having a face electrode located on a face surface  
15       of the spacer; and  
        a common bus structure connecting the face  
electrodes.

5.    The flat panel display of Claim 4, wherein  
20    each spacer further comprises an edge electrode located  
on an edge surface of the spacer, the face electrode of  
the spacer contacting the edge electrode of the spacer.

6.    The flat panel display of Claim 4, wherein  
25    the common bus structure comprises:  
        an insulating strip located on the faceplate  
adjacent to the light emitting structure; and  
        a conductive bus layer located on the  
insulating strip, wherein the conductive bus layer  
30    is connected to the face electrodes.

7.    The flat panel display of Claim 4, wherein  
each spacer comprises a first edge electrode located at  
a first edge of the spacer and a second edge electrode  
35    located at the first edge of the spacer, the first and  
second edge electrodes being separated by a gap, such



that the first edge electrode contacts the light emitting structure, and the second edge electrode contacts the common bus structure.

5           8.    The flat panel display of Claim 4, further comprising a capacitor connected to the common bus structure.

10           9.    The flat panel display of Claim 8, further comprising a sidewall structure which extends between the faceplate and backplate structures, the sidewall structure substantially laterally surrounding the light emitting structure, the electron emitting structure and the common bus structure, wherein the capacitor is  
15           located outside the outer perimeter of the sidewall structure.

20           10.   The flat panel display of Claim 8, wherein the capacitor is connected between the common bus structure and a ground voltage supply.

25           11.   The flat panel display of Claim 8, wherein the capacitor is connected between the common bus structure and a high voltage supply.

30           12.   The flat panel display of Claim 8, wherein the bus structure comprises:  
              a dielectric strip located over the faceplate adjacent to the light emitting structure; and  
              a conductive bus layer located over the insulating strip, wherein the conductive bus layer is connected to the face electrodes.

35           13.   The flat panel display of Claim 12, wherein the capacitor comprises the conductive bus layer, the dielectric strip, and a second conductive layer located

between the faceplate and the dielectric strip, wherein the second conductive layer is connected to a high voltage supply through the light emitting structure.

5           14. The flat panel display of Claim 13, wherein the second conductive layer is located in a groove in the faceplate.

10           15. A flat panel display comprising:  
            a faceplate structure having an insulating faceplate and a light emitting structure, the light emitting structure being arranged in a plurality of parallel pixel rows;  
            a backplate structure having an insulating  
15           backplate and an electron emitting structure;  
            a plurality of spacers located between the faceplate and backplate structures, each spacer being located perpendicular to the pixel rows, each spacer having a face electrode located on a  
20           face surface of the spacer.

            16. A spacer material for a flat panel display comprising:  
            aluminum oxide;  
25           chromium oxide dispersed in the aluminum oxide; and  
            titanium oxide dispersed in the aluminum oxide, wherein the spacer material comprises approximately 4 percent titanium oxide.

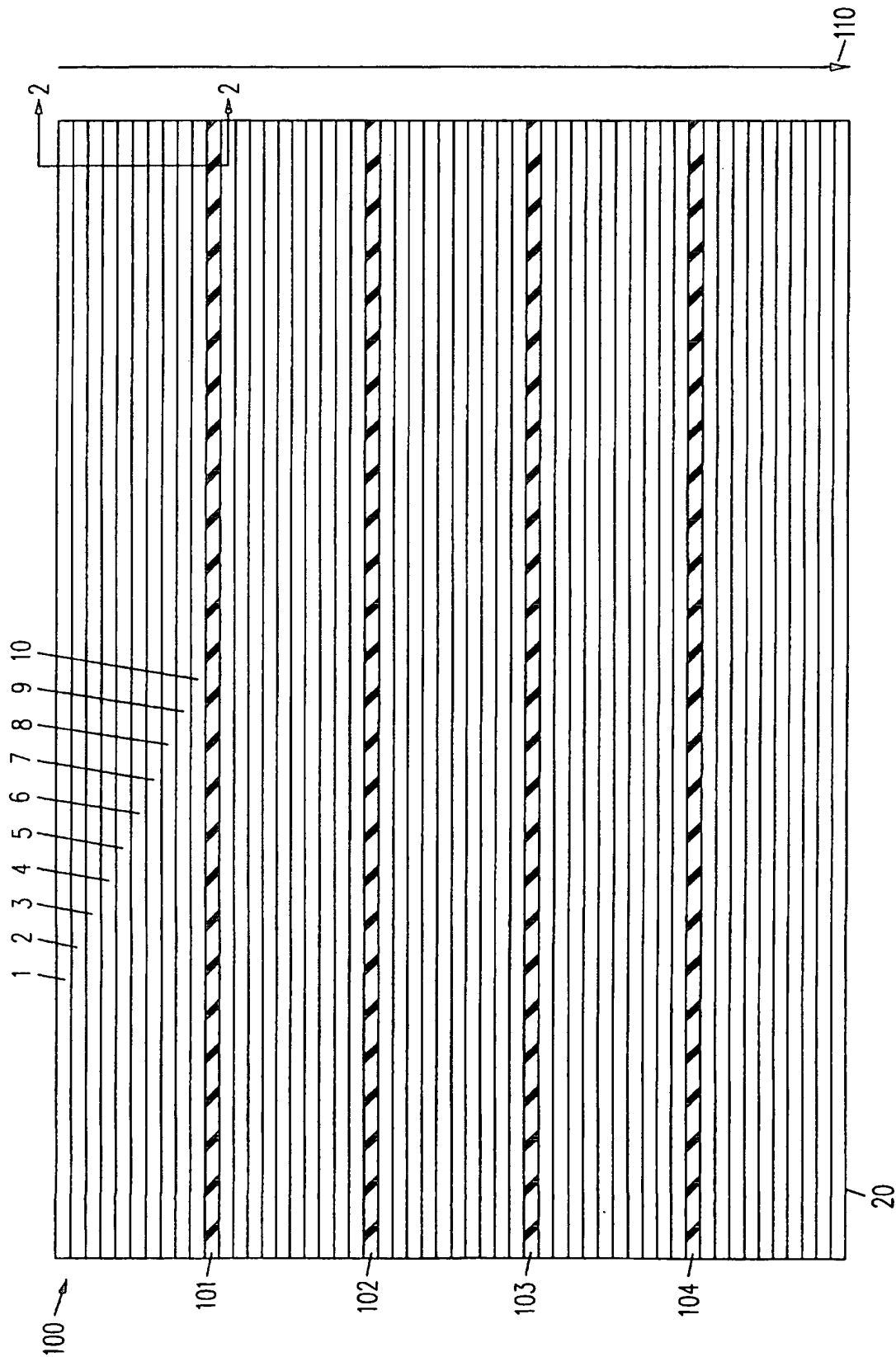
30           17. The spacer material of Claim 16, wherein the spacer material comprises approximately 32 percent aluminum oxide and approximately 64 percent chromium oxide.

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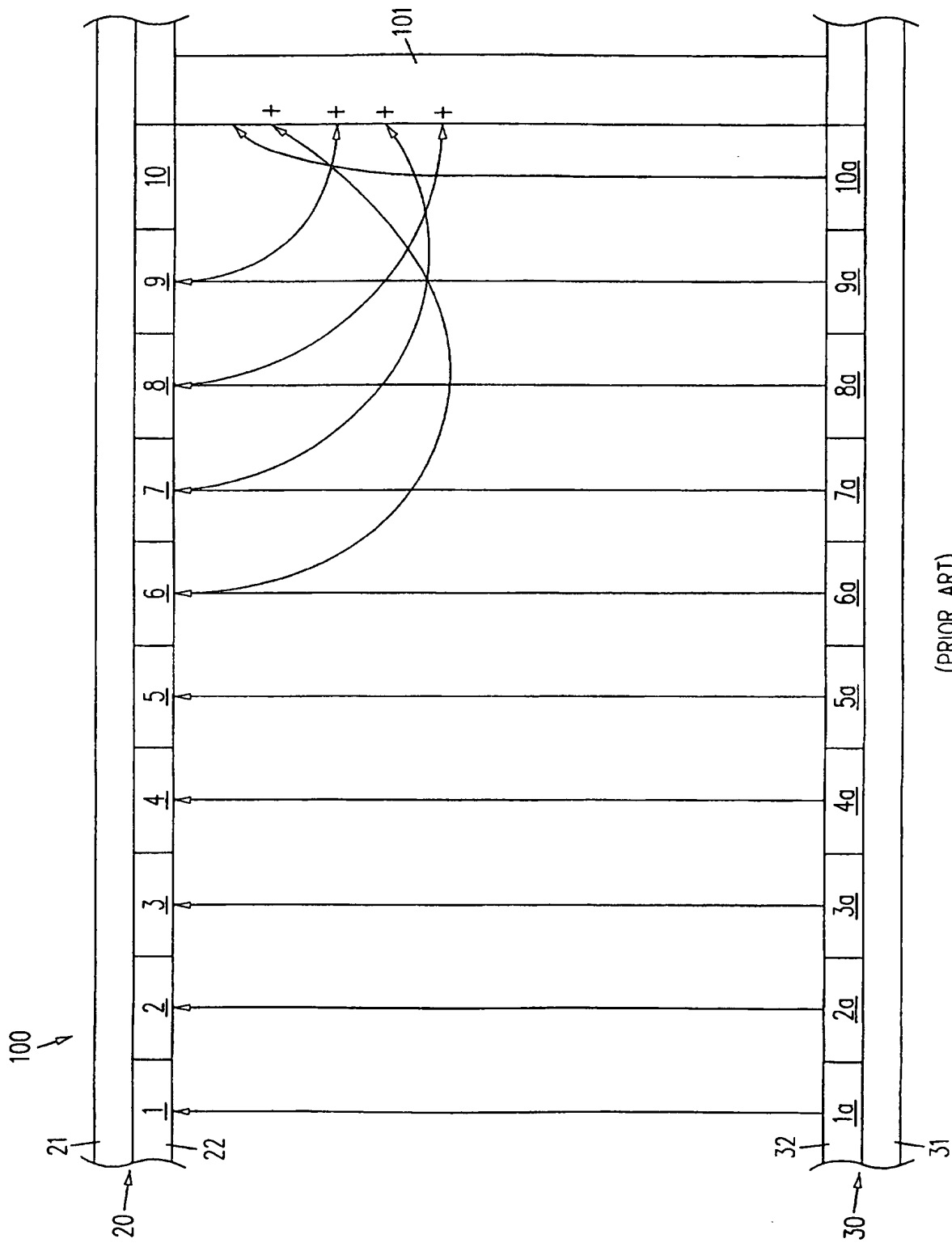
18. A spacer for a flat panel display comprising a material having a dielectric constant greater than  $100\epsilon_0$ .

5           19. The spacer of Claim 18, wherein the spacer comprises a material having a dielectric constant in the range of  $400\epsilon_0$  to  $800\epsilon_0$ .

10           20. The spacer of Claim 18, wherein the spacer comprises a material having a dielectric constant in the range of  $700\epsilon_0$  to  $750\epsilon_0$ .



(PRIOR ART)  
FIG. 1



(PRIOR ART)  
FIG. 2

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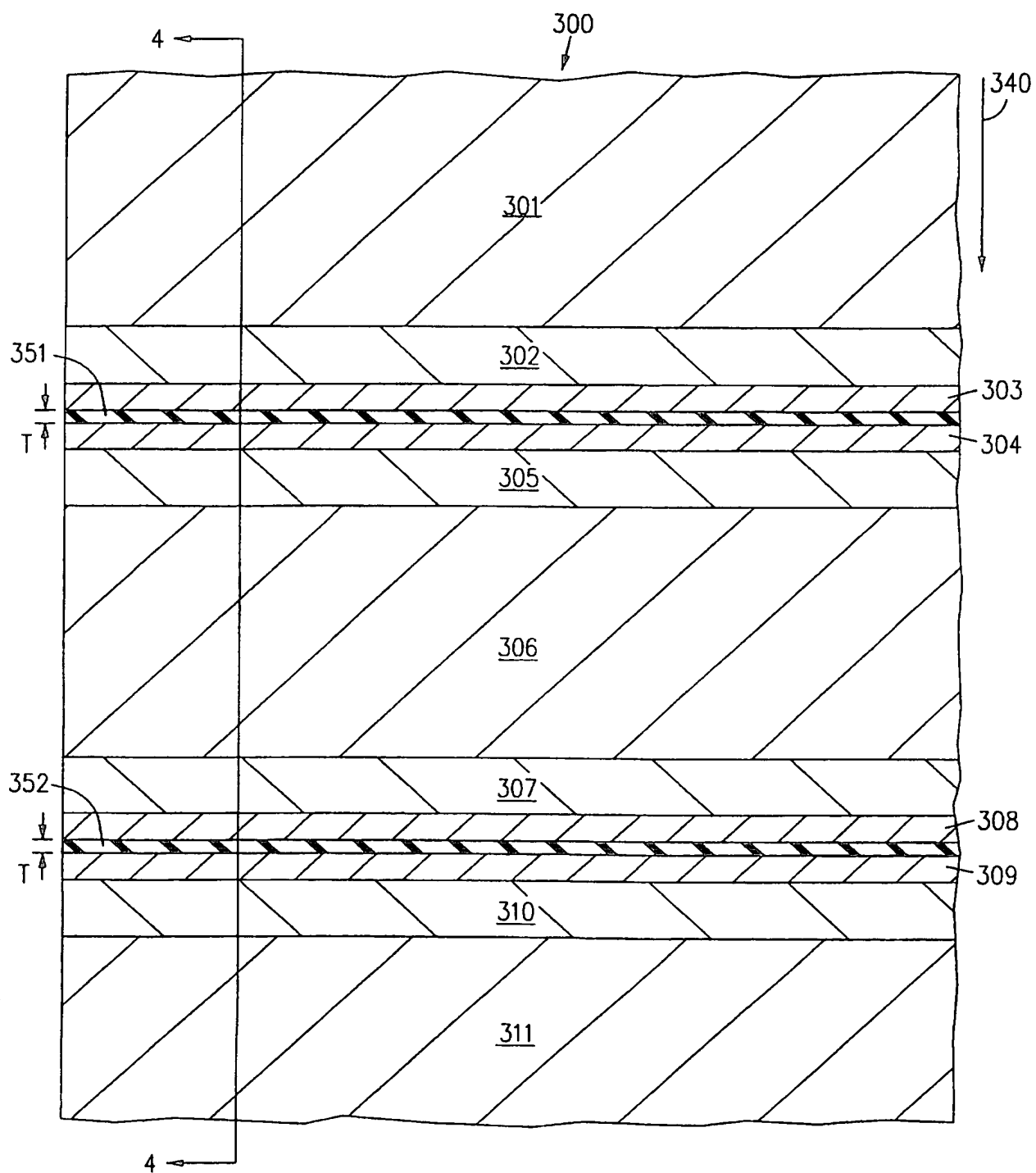


FIG. 3

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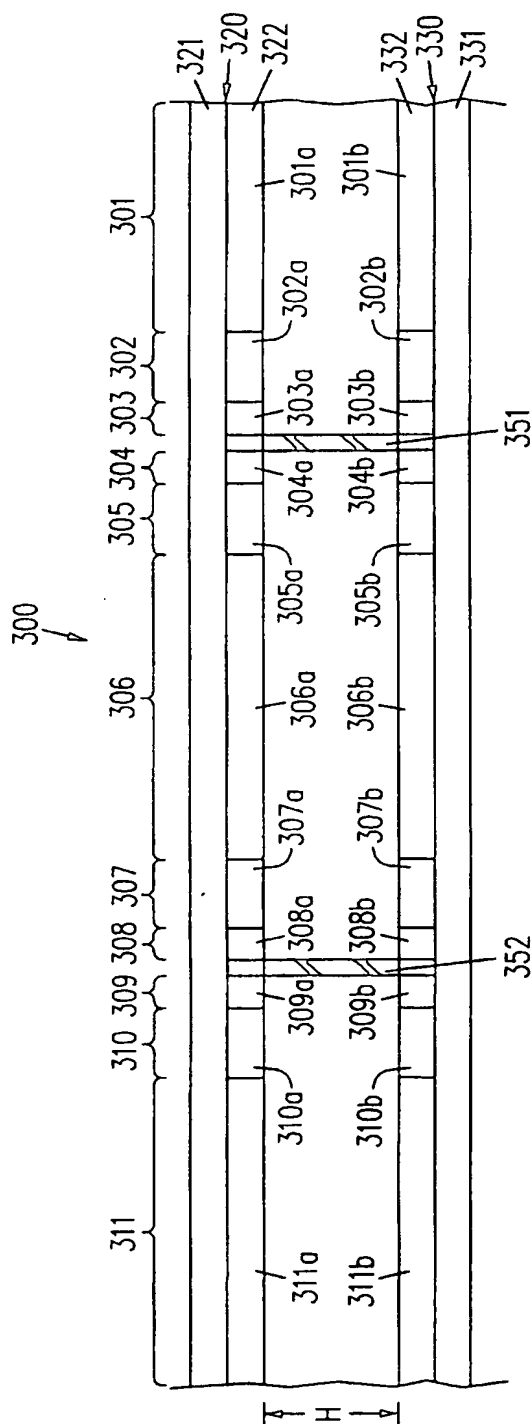


FIG. 4

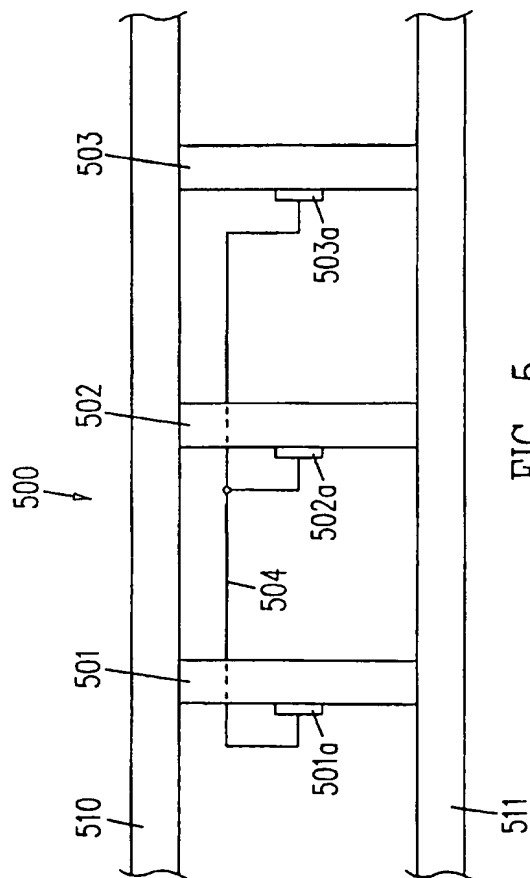


FIG. 5

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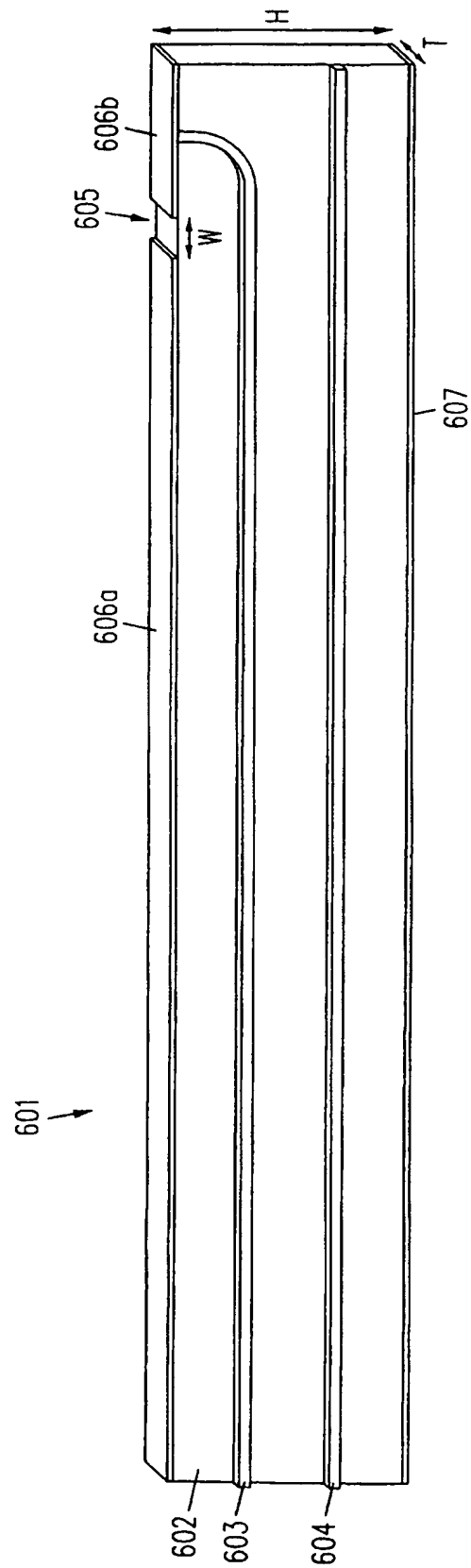


FIG. 6



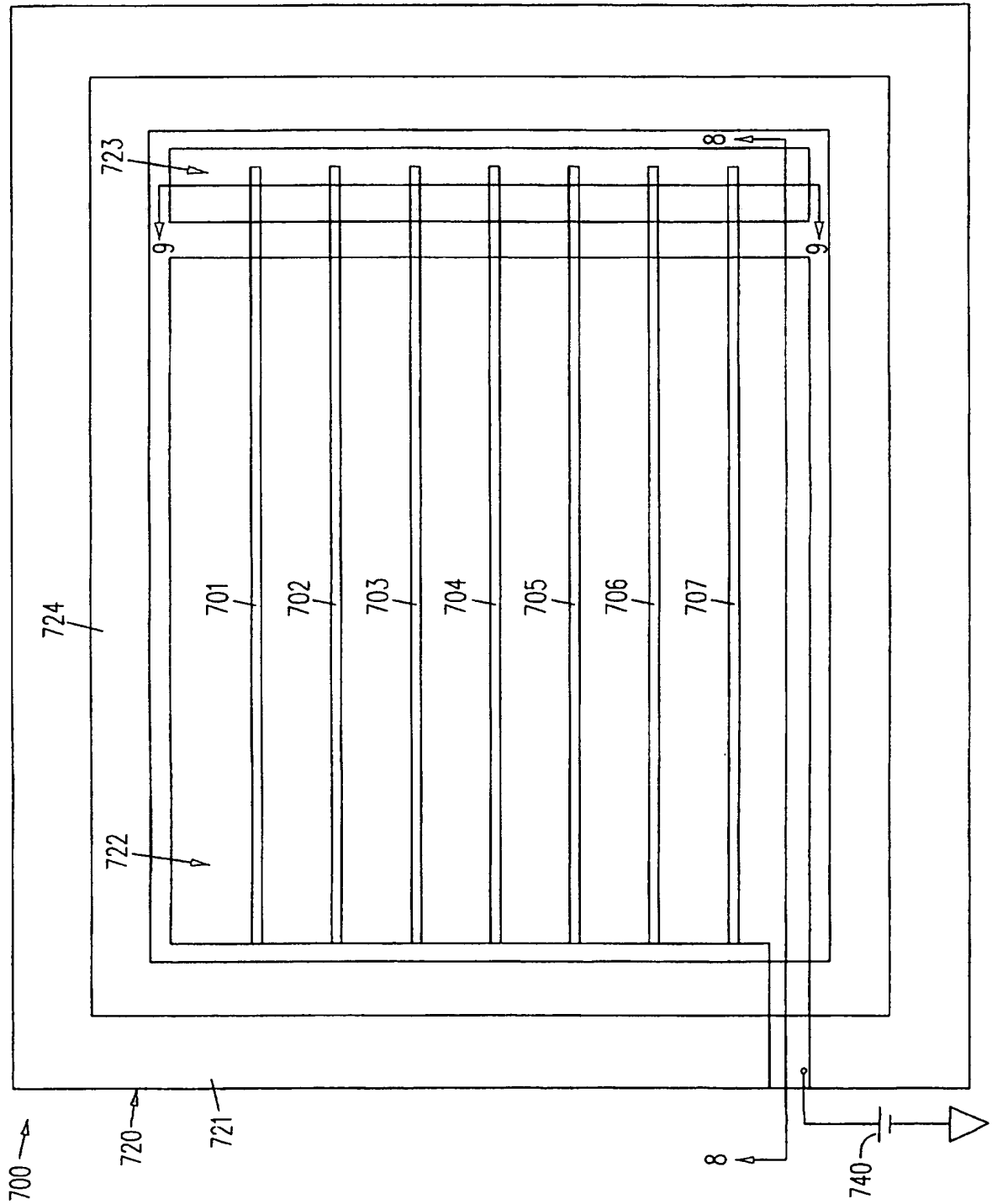


FIG. 7

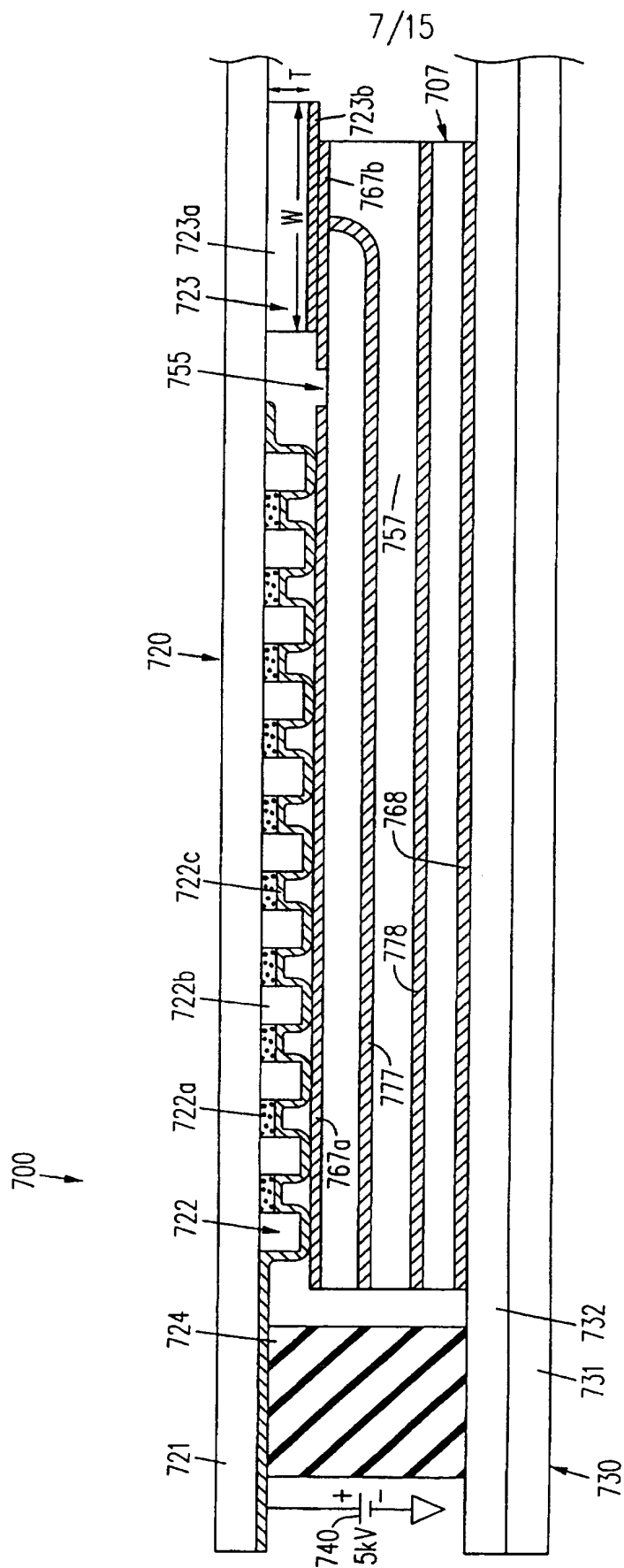
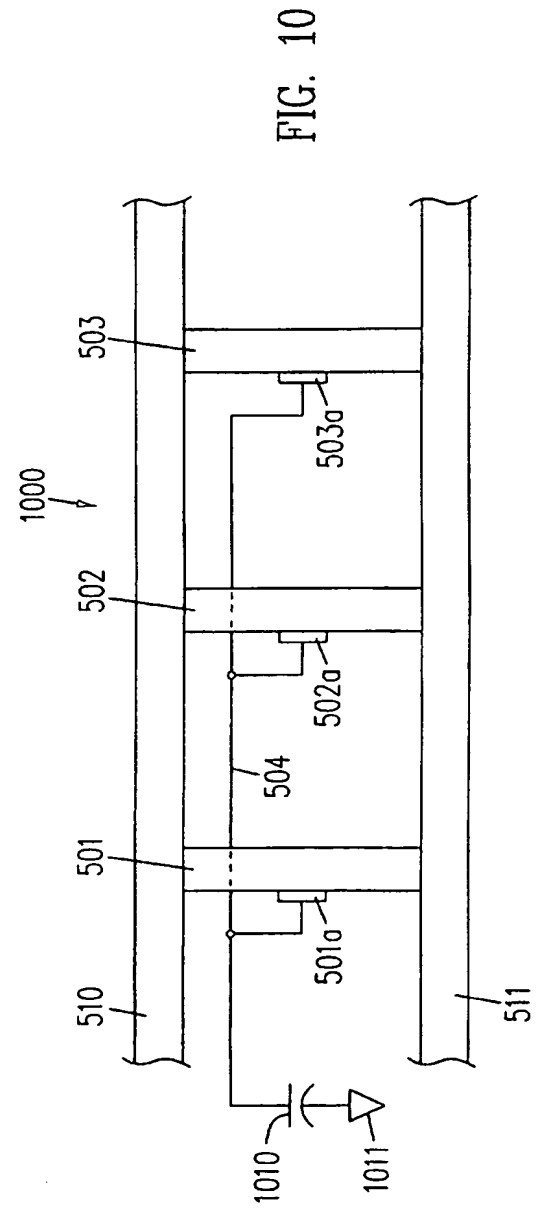
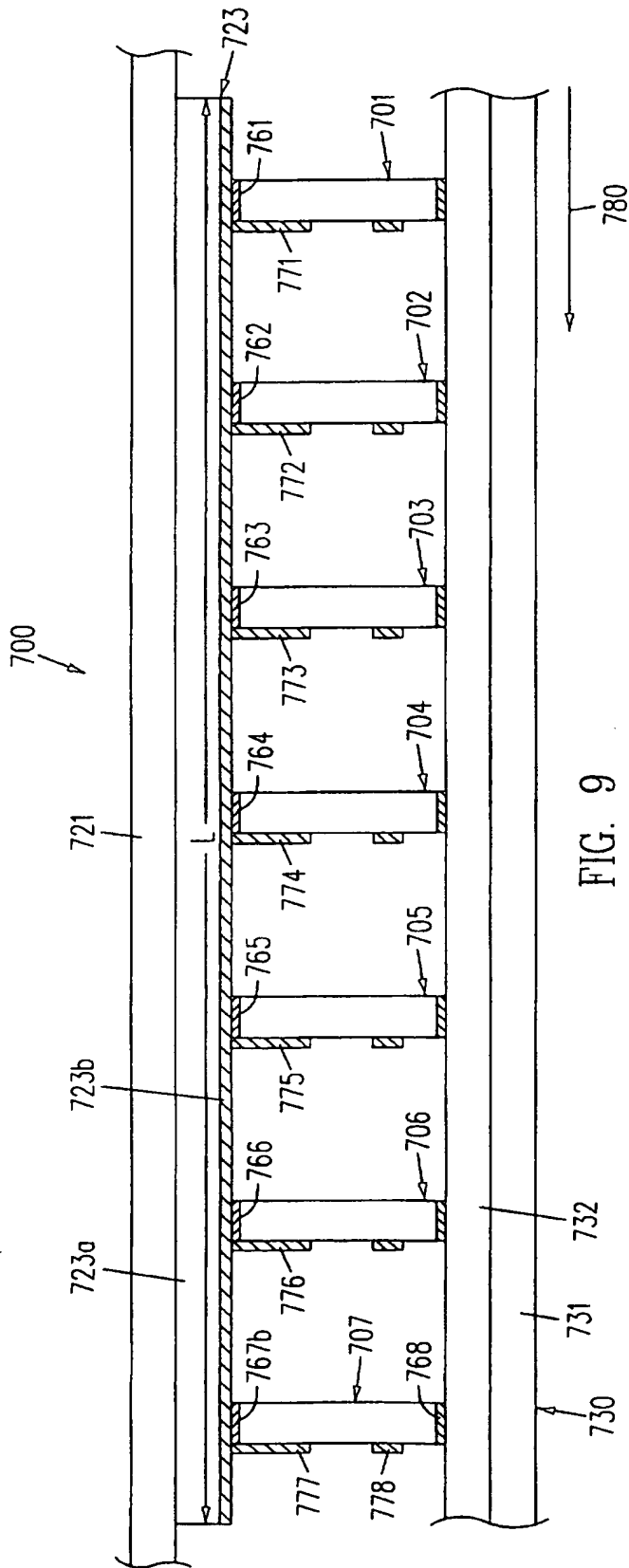
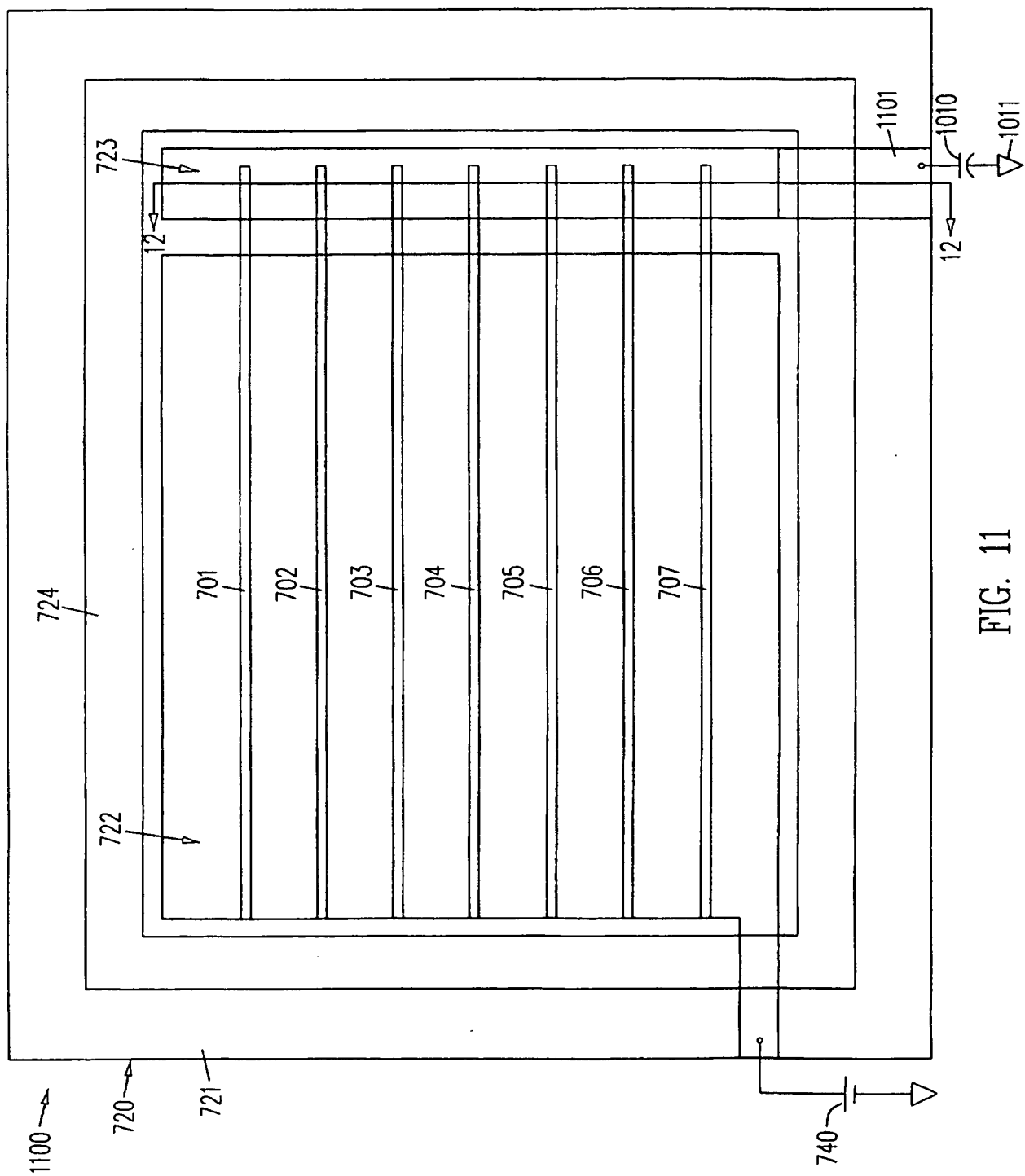


FIG. 8

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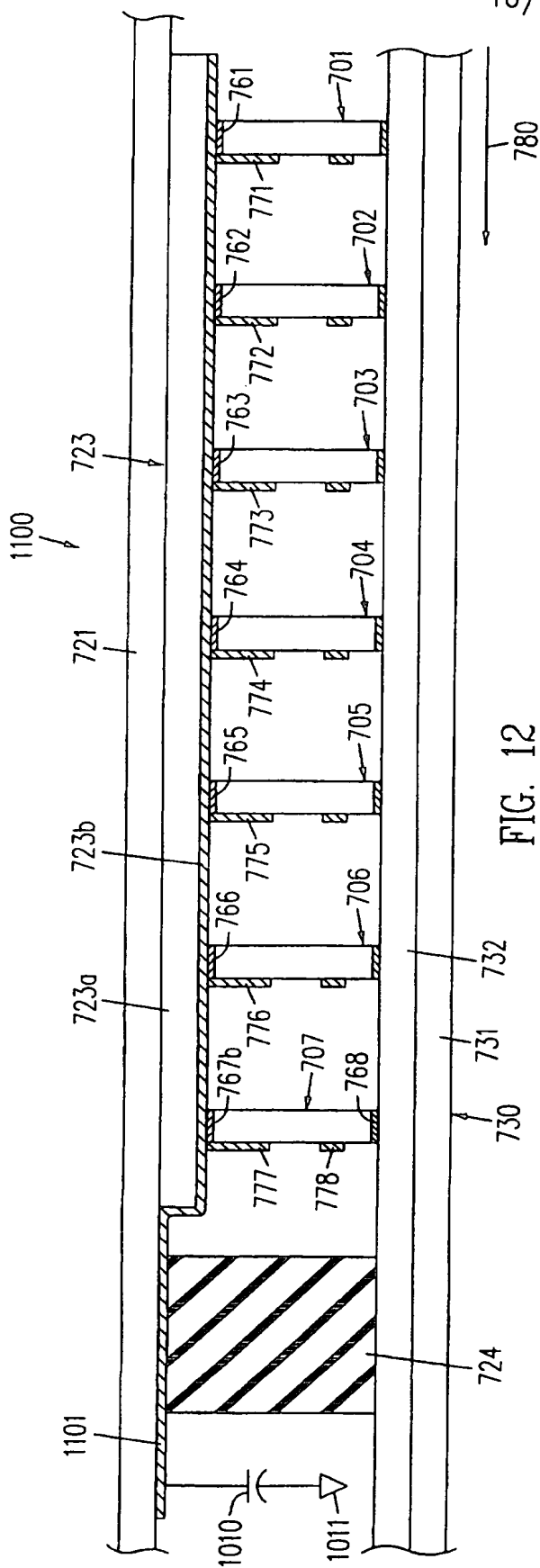


FIG. 12

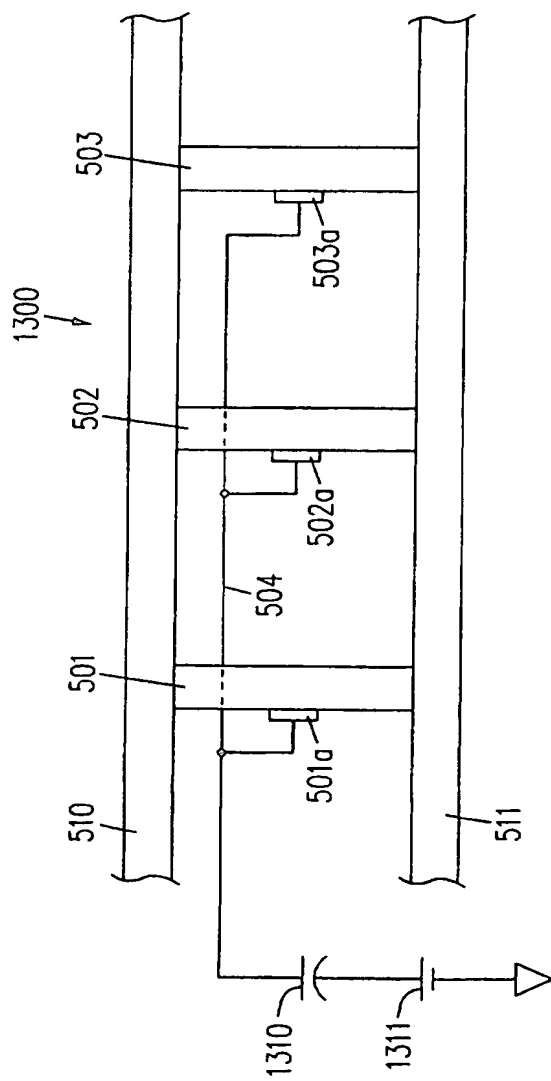


FIG. 13

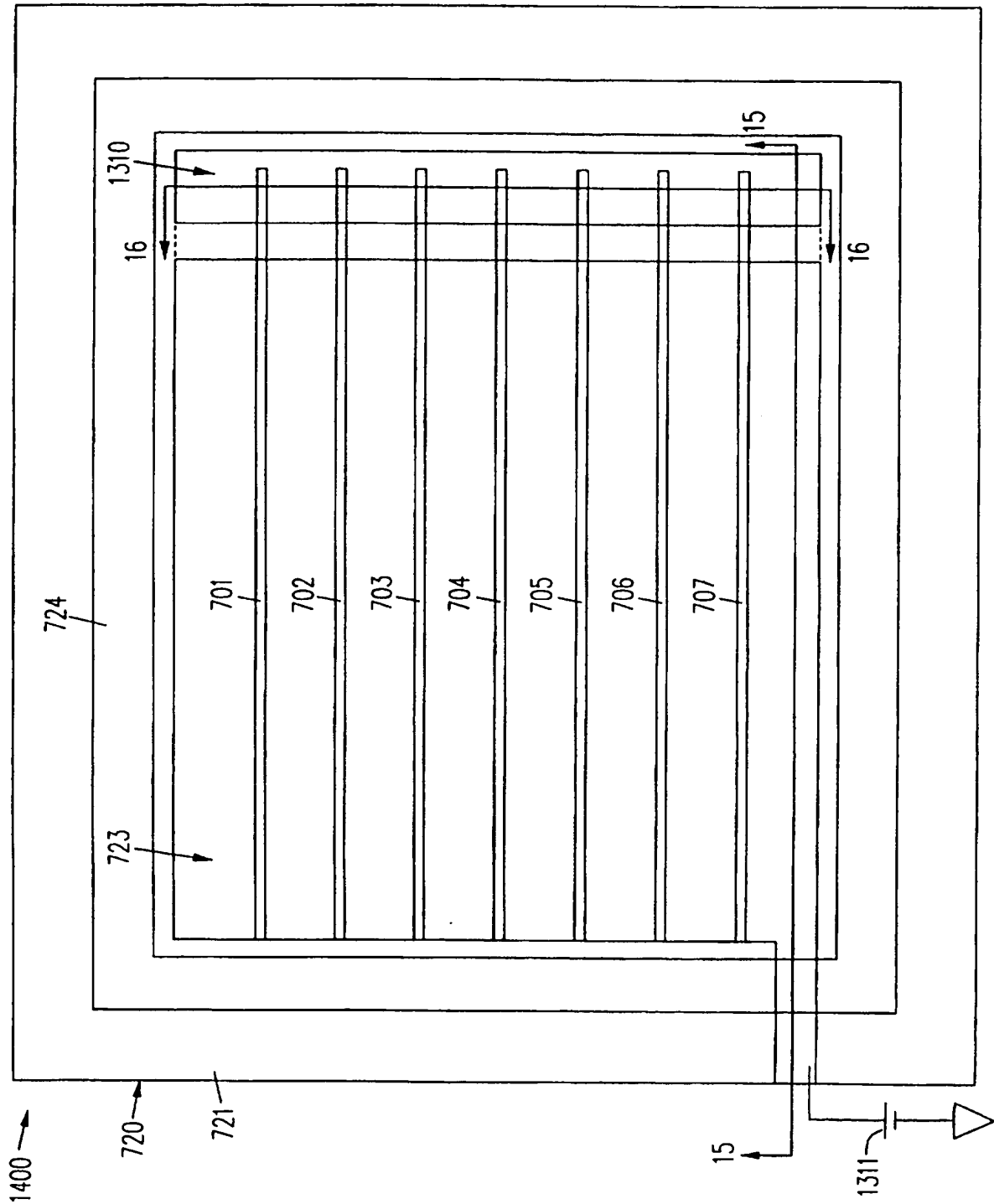


FIG. 14

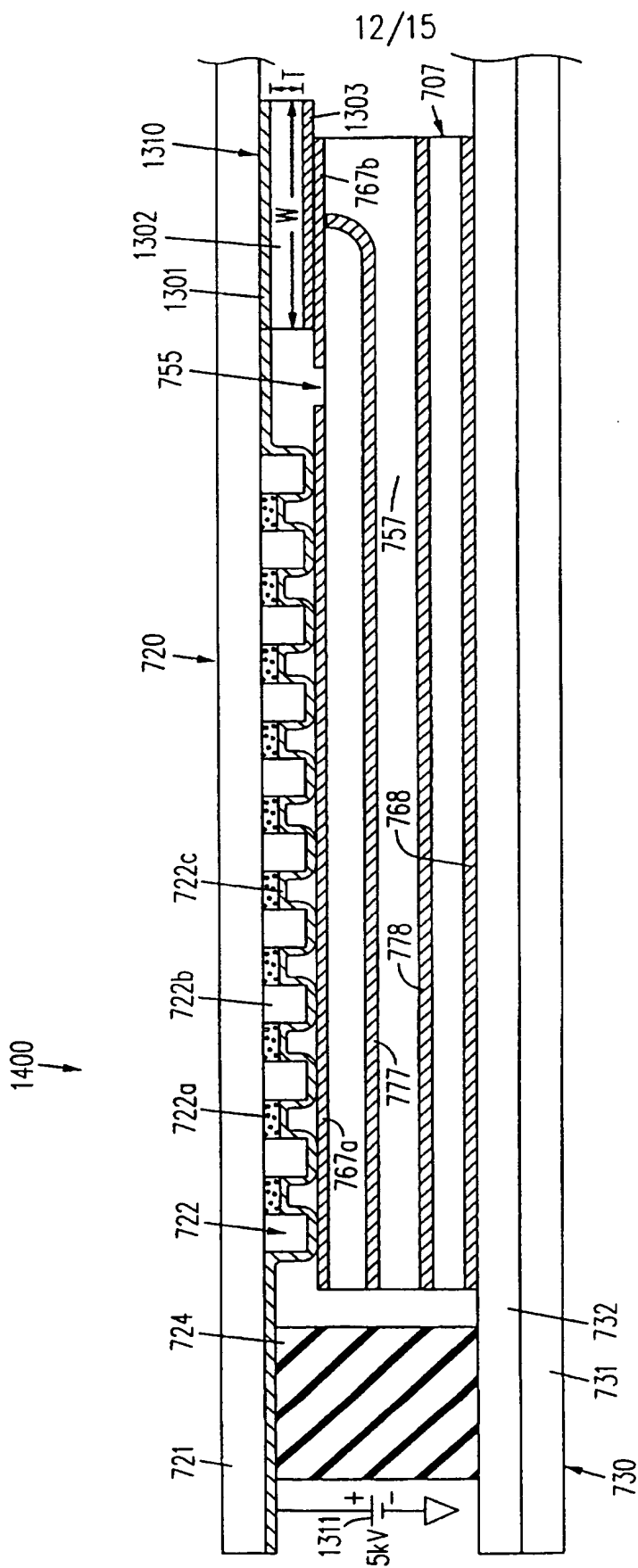


FIG. 15

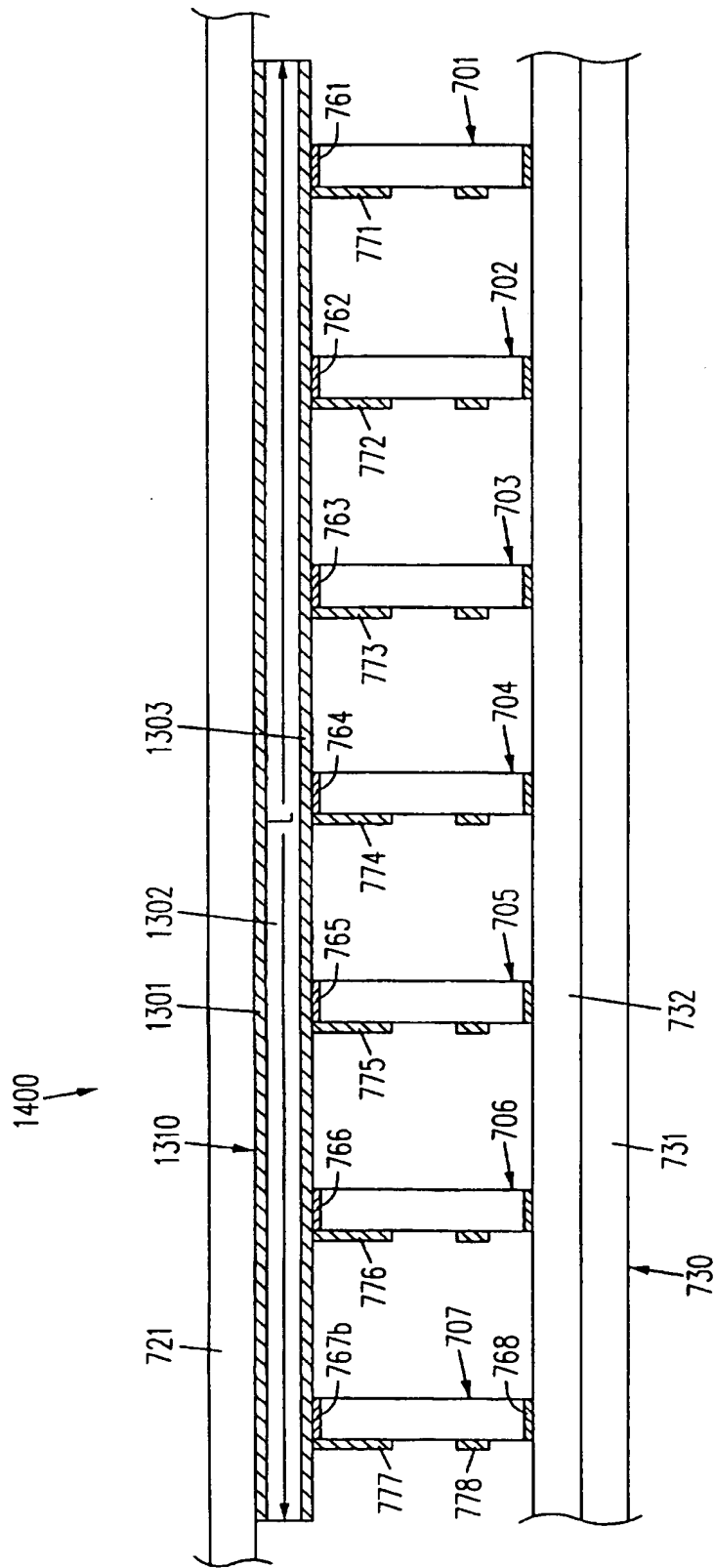


FIG. 16



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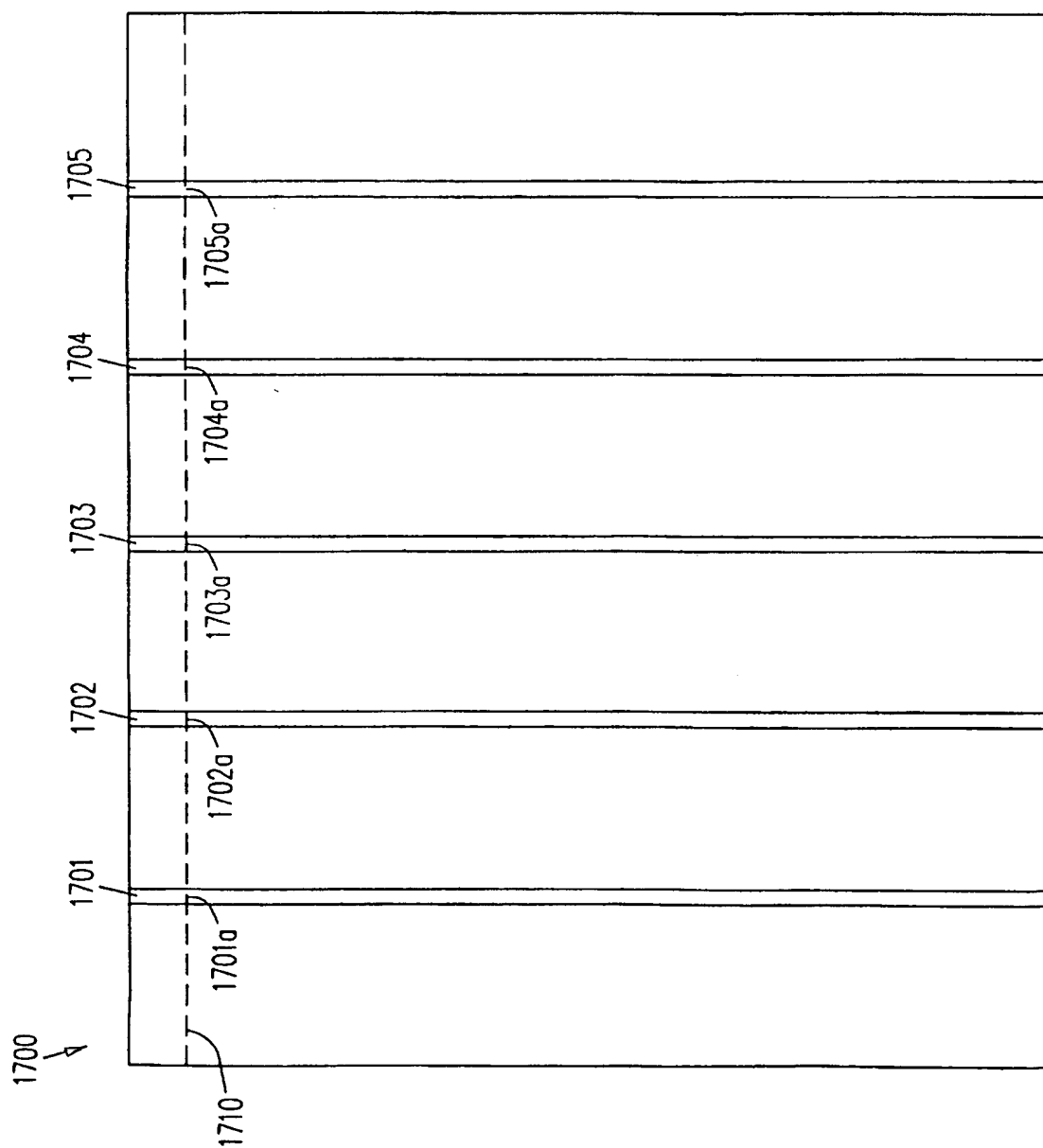


FIG. 17

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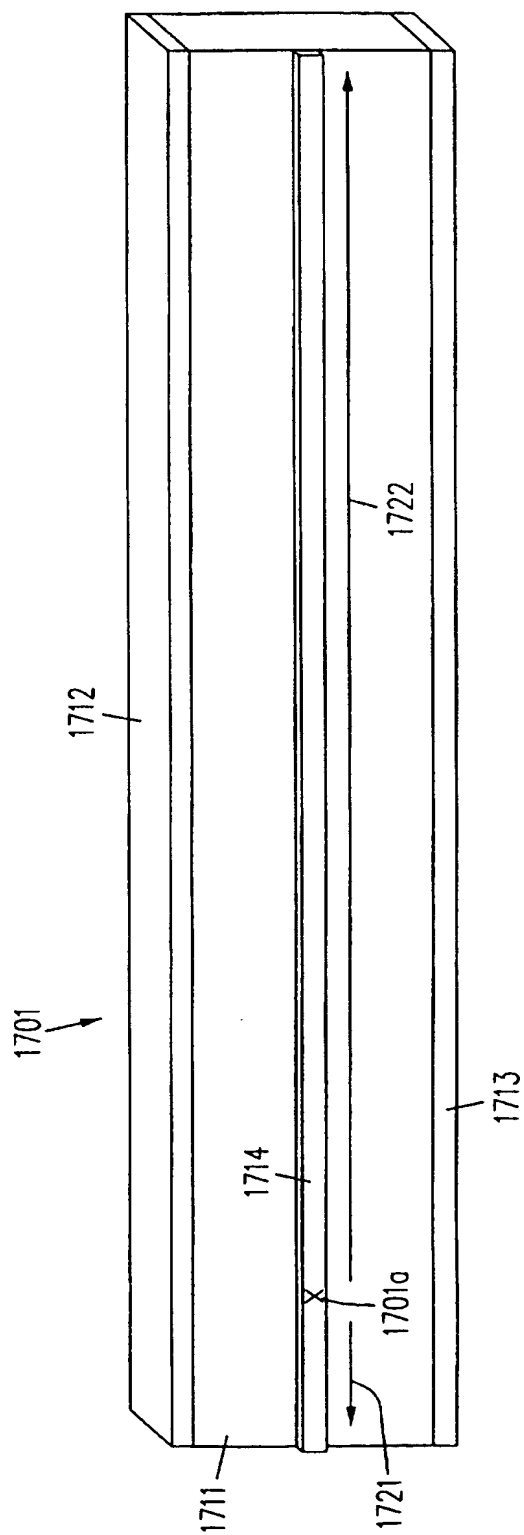


FIG. 18

## INTERNATIONAL SEARCH REPORT

 International application No.  
 PCT/US97/11917

<b>A. CLASSIFICATION OF SUBJECT MATTER</b> IPC(6) : H01J 1/62, 63/04 US CL : 313/495-497, 422, 482, 309, 395-397, 258, 292, 306, 311 According to International Patent Classification (IPC) or to both national classification and IPC		
<b>B. FIELDS SEARCHED</b> Minimum documentation searched (classification system followed by classification symbols) U.S. : 313/495-497, 422, 482, 309, 395-397, 258, 292, 306, 311 Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)		
<b>C. DOCUMENTS CONSIDERED TO BE RELEVANT</b>		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Y	US 5,532,548 A (SPINDT et al.) 02 July 1996, Fig. 3	4-5, 7, 15
Y,P	US 5,589,731 A (FAHLEN et al.) 31 December 1996, Fig. 2A	4-5, 7, 15
Y	US 5,177,410 A (HASHIGUCHI et al.) 05 January 1993, Col. 6, line 63	18-20
A, P	US 5,578,899 A (HAVEN et al.) 26 November 1996, Fig. 2.	4,15
A	US 4,745,332 A (TISCHER) 17 May 1988, Col. 4, line 51	16, 17
<input type="checkbox"/> Further documents are listed in the continuation of Box C. <input type="checkbox"/> See patent family annex.		
* Special categories of cited documents: "A" document defining the general state of the art which is not considered to be of particular relevance "B" earlier document published on or after the international filing date "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) "O" document referring to an oral disclosure, use, exhibition or other means "P" document published prior to the international filing date but later than the priority date claimed "T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principles or theory underlying the invention "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art "A" document member of the same patent family		
Date of the actual completion of the international search 06 NOVEMBER 1997		Date of mailing of the international search report 23 DEC 1997
Name and mailing address of the ISA/US Commissioner of Patents and Trademarks Box PCT Washington, D.C. 20231 Facsimile No. (703) 305-3230		Authorized officer <i>Jay M. Patidar</i> JAY M. PATIDAR Telephone No. (703) 308-6723